Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	65	"ammonium oxalate" and benzotriazole and slurry	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:19
L4	110	"ammonium oxalate" same slurry	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 14:37
L6	24	"ammonium oxalate" and silane and polish\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 14:40
L7	224	ureidopropyltrimethoxysilane	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:12
L9	56834	CMP or "chemical mechanical polishing"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:15
L10	1951	("ammonium oxalate" or chelating or buffer) and benzotriazole and slurry	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:17
L-1-1	347	9 and 10	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:17
L12	1411	("ammonium oxalate" or chelating or buffer) and (silane or hydroxyl or ligand) and benzotriazole and slurry	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:18
L13	5	12 and 7	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:18

L15	8	chou-homer.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:20
L16	7	hawkins-joseph-d.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:21
L17	9	zhou-renjie.in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/04/15 15:21